

In re application of

Shinichi IGARASHI et al.

Confirmation No. 1708

Appl. No. 10/566,158

: Art Unit 2881

Filed January 27, 2006

: Examiner Smyth, Andrew P.

TWO-DIMENSIONAL PATTERNING METHOD, AND MANUFACTURING METHOD OF ELECTRONIC DEVICE AND MAGNETIC DEVICE USING THE TWO-DIMENSIONAL PATTERNING METHOD Attorney Docket No. 2006-0079A

AMENDMENT UNDER 37 C.F.R. 1.111

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action having a mailing date of March 21, 2008, the period for response having been extended for one month by the attached petition, please amend the above-referenced U.S. patent application as follows: